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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): SUGIYAMA et al.

Atty. Dkt.: 01-609

Serial No.: 10/814,179

Group Art Unit: 1722

Filed: April 1, 2004

Examiner: KUNEMUND, Robert M.

Title: **EQUIPMENT AND METHOD FOR  
MANUFACTURING SILICON  
CARBIDE SINGLE CRYSTAL**

Commissioner for Patents  
Alexandria, VA 22313-1450

Date: November 14, 2006

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Sir:

Pursuant to 37 C.F.R. §1.56, the reference(s) listed on the attached Form PTO-1449 is/are being brought to the attention of the Examiner without any admission that it/they constitute(s) statutory prior art, or without any admission that it/they contain(s) subject matter that anticipates the invention or renders the invention obvious to a person of ordinary skill in the art.

Further, pursuant to 37 C.F.R. §1.97(e), the undersigned hereby certifies that each listed reference was first cited in a Communication (copy and English translation enclosed) from a foreign patent office in connection with a counterpart foreign application not more than three months prior to the filing of this statement.

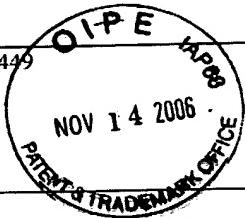
Although no fees are believed to be due at this time, it is respectfully requested that any such fees be charged to Deposit Account 50-1147. Also, the Examiner is requested to initial the attached PTO Form-1449 and to return a copy of same to the undersigned attorney as proof that the listed reference(s) has/have been considered and made of record.

Respectfully submitted,

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FORM PTO-1449	ATTY. DKT NO. 01-609	SER. NO. 10/814,179
APPLICANT SUGIYAMA et al.		
FILING DATE April 1, 2004	GROUP 1722	



**REFERENCE DESIGNATION**

**U.S. PATENT DOCUMENTS**

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS

**FOREIGN PATENT DOCUMENTS**

**TRANSLATION**

		DOCUMENT NUMBER	DATE	COUNTRY	NAME	CLASS	SUB CLASS	YES	NO	
										Eng. Abstract

\* Full English text is available in machine-translated form in JPO (Japanese Patent Office) English language web site at <http://www1.ipdl.jpo.go.jp/PA1/cgi-bin/PA1INDEX>.

**OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)**

		Notice of Reason for Refusal from Japanese Patent Office issued on October 17, 2006 for the corresponding Japanese patent application No. 2003-102016 (a copy and English translation thereof)
EXAMINER	DATE CONSIDERED	